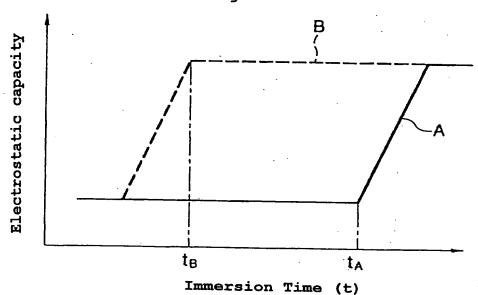


Fig. 2



B: Photosensitive material in which the developing solution is easily immersed.

t_B: Time in which electrostatic capacity is changed.

A: Photosensitive material in which the developing solution is immersed with difficulty.

 T_a : Time in which electrostatic capacity is changed.

Fig. 3

The change of the film thickness is detected by the coherent

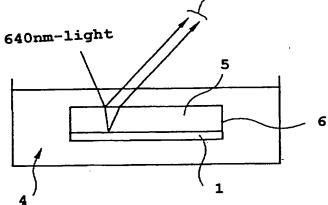
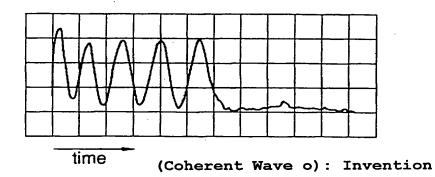
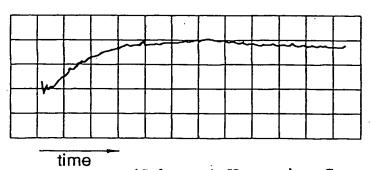


Fig. 4





(Coherent Wave x): Conventional

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FIG. 1

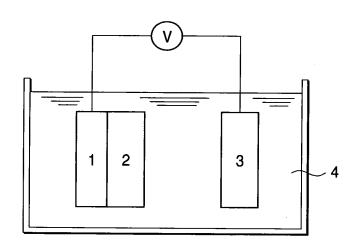
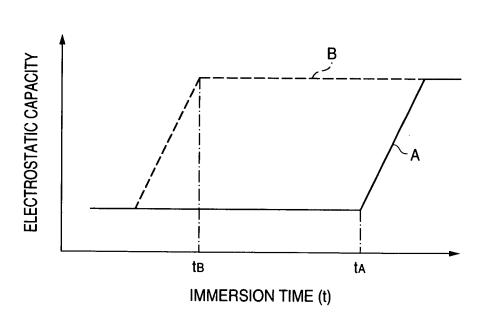


FIG. 2



- B: PHOTOSENSITIVE MATERIAL IN WHICH THE DEVELOPING SOLUTION IS EASILY
- tB: TIME IN WHICH ELECTROSTATIC CAPACITY IS CHANGED
- A: PHOTOSENSITIVE MATERIAL IN WHICH THE DEVELOPING SOLUTION IS IMMERSED WITH DIFFICULTY
- Ta: TIME IN WHICH ELECTROSTATIC CAPACITY IS CHANGED

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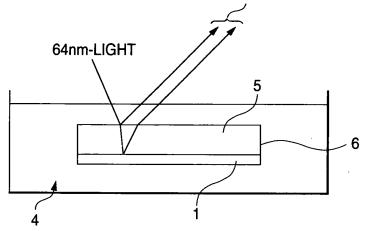
INVENTOR(S): MITSUMASA TSUCHIYA ET AL.

DOCKET NO: 019519-409

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FIG. 3

THE CHANGE OF THE FILM THICKNESS IS DETECTED BY THE COHERENT



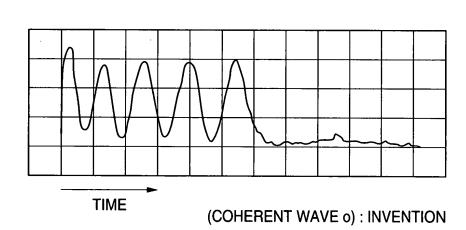
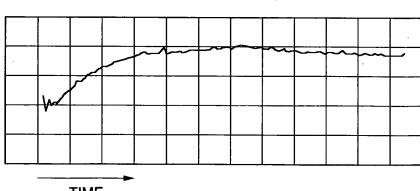


FIG. 4



TIME

(COHERENT WAVE x): CONVENTIONAL